



IFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 3698**
Jyun IWASHITA et al. : Attorney Docket No. 2005_1513A
Serial No. 10/549,849 : Group Art Unit 1795
Filed December 12, 2005 : Examiner Ponder N. Thompson Rummel
NEGATIVE RESIST COMPOSITION AND : **Mail Stop: AMENDMENT**
METHOD OF FORMING RESIST PATTERN

RESPONSE

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEES FOR THIS PAPER TO DEPOSIT
ACCOUNT NO 23-0975

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated October 26, 2007, please amend the present application as follows: